IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No. : 10/791,763

Applicant : Wolfgang Dettmann et al.

Confirmation No. : 4420

Filed : March 4, 2004

TC/A.U. : 1795

Examiner : Ruggles, John S.

Customer No. : 71737

Docket No. : 3000.0036C

Title : Set of at Least Two Masks for the Projection of Structure

Patterns and Method for Producing the Masks

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Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

AMENDMENT ACCOMPANYING REQUEST FOR CONTINUED EXAMINATION AND

RESPONSE TO NOTICE OF NON-COMPLIANT AMENDMENT

Sir:

In response to the final Office Action mailed September 14, 2007, and the Advisory Action and Notice of Non-Compliant Amendment mailed December 20, 2007, please amend the above-identified application as follows:

Amendments to the Specification: None.

Amendments to the Claims: reflected in the listing of claims, which begins on page 2 of this paper.

Remarks: begin on page 4 of this paper.